

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s)

: Theodore M. Bloomstein

Application No. : 09/922,973

Filed

: August 6, 2001

Entitled

: STEREOLITHOGRAPHIC

PATTERNING WITH VARIABLE

SIZE EXPOSURE AREAS

Docket No.

: 101328-160

First Class Mail (37 C.F.R. 1.8)

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Engellenger Reg. No. 28,711

Group Art Unit: 1756

Examiner: Kripa Sagar

Autorney for Applicant(s)

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Applicant herewith makes of record the enclosed references in accordance with §1.97(c) and (e)(2). These documents are cited on the enclosed PTO Form-1449, and a copy of each document cited thereon are enclosed as well.

The undersigned hereby certifies that no item of information contained in the Supplemental Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart foreign application, and, to my knowledge, after making reasonable inquiry, no item of information contained in the Supplemental Information Disclosure Statement was known to any individual designated in § 1.56(c) more than three months prior to the filing of

Application No.: 09/922,973 Filing Date: August 6, 2001 Atty. Docket No.: 101328-160

this Supplemental Information Disclosure Statement. No additional costs are believed to be due in connection with the filing of this Supplemental Information Disclosure Statement. However, please charge any necessary fees in connection with the enclosed statement to our Deposit Account No. 141449.

Date: 8 October 2003

Thomas J. Engellenner

Reg. No. 28,711

Respectfully submi

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PTO/SB/08B (10-01)
Approved for use through 10/31/2002.OMB 0651-0031
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Substitute for form 1449B/PTO				Complete if Known		
				Application Number	09/922,973	
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5	STATEMENT I	3Y /	APPLICANT	First Named Inventor	Theodore M. Bloomstein	
				Group Art Unit	1756	
	(use as many sh	eets as	necessary)	Examiner Name	Kripa Sagar	
Sheet	1	of	1	Attorney Docket Number	101328-160	

U.S. PATENT DOCUMENTS							
Examiner Initials*	Cite No.1	Document Number	Publication Date	Name of Patentee or Applicant	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
		Number-Kind Code <sup>2</sup> (if known)	MM-DD-YYYY	of Cited Document			
		5,182,056	01/26/1993	Spence et al.			
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OTHER PRIOR ART – NON PATENT LITERATURE DOCUMENTS					
Examiner Cite No.1		Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc), date, page(s), volume-issue number(s), publisher, city and/or country where published.			
		Gale et al. "Fabrication of Continuous-relief micro-optical elements by direct laser writing in photoresists" <i>Optical Engineering</i> , vol. 33, no. 11, pgs. 3556-3566 (1994).			
		Chen et al. "Predicting total build-time and the resultant cure depth of the 3D stereolithography process" Rapid Prototyping Journal, vol. 2, no. 4, pgs. 27-40 (1996).			
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